CLAIMS

What is claimed is:

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A method of adjusting the planarity of a substrate in a probe card assembly, the

- 2 method comprising:
- deflecting at least one of a first area of the substrate, a second area of the
- 4 substrate, a third area of the substrate, and a fourth area of the substrate;
- 5 said deflecting comprising applying a pulling force to said at least one of said
- 6 first, second, third, and fourth areas of the substrate.
 - 2. A method as in claim 1 wherein at least said first area is a non-peripheral area of the substrate.
 - 3. A method as in claim 1 wherein said deflecting further comprises applying a pushing force to at least one of said first, second, third, and fourth areas to which said pulling force is not applied.
- 1 4. A method as in claim 1 wherein said deflecting is performed manually.
- 1 5. A method as in claim 1 wherein said deflecting is performed automatically.
- 1 6. An interposer for use with a probe card assembly, the interposer comprising:
- a non-peripheral opening capable of receiving an actuating assembly for
- 3 deflecting a space transformer in the probe card assembly.

- 7. A method of achieving a degree of planarity among contact portions of a plurality of contact structures mounted to a substrate, the method comprising:

 creating the substrate with the plurality of contact structures coupled to a first surface of the substrate, the contact portions of the contact structures having a first
- applying a plurality of forces selectively to the substrate to deform the substrate

 and achieve a second planar relationship of the contact portions of the contact

 structures relative to one another.

planar relationship relative to one another;

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- 8. A method as in claim 7 wherein a plurality of substrates are deformed on a combined assembly.
- 9. A method as in claim 8 wherein a rotational adjustment is performed on at least one of the substrates in said combined assembly.
- 1 10. A method as in claim 8 wherein a translational adjustment is performed on at least one of the substrates in said combined assembly.